



AF/2815

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

ATTORNEY DOCKET NO. 025311/0105

Endler
10/22/02

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Amdt
ATE

J. Macmillan
9/20/02

Applicant: Ichiro OKABE *et al.* ✓

Title: METHOD OF FORMING A FINE PATTERN, AND METHOD OF
MANUFACTURING A SEMICONDUCTOR DEVICE, AND A
SEMICONDUCTOR DEVICE HAVING A FINE PATTERN

Appl. No.: 09/597,161 ✓

Filing Date: 06/20/2000 ✓

Examiner: J. Diaz

Art Unit: 2815

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AMENDMENT AND REPLY UNDER 37 C.F.R. § 1.116

Commissioner for Patents
Washington, D.C. 20231
BOX AF

Sir:

In response to the Office Action mailed June 13, 2002, please amend the application as follows:

In the Claims:

Please cancel claims 2 and 4 without prejudice or disclaimer.

In accordance with 37 C.F.R. § 1.121(c)(1), please substitute for original claims 1 and 5 the following rewritten versions of the same claims, as amended. The changes are shown explicitly in the attached "Versions With Markings To Show Changes Made."